

#3

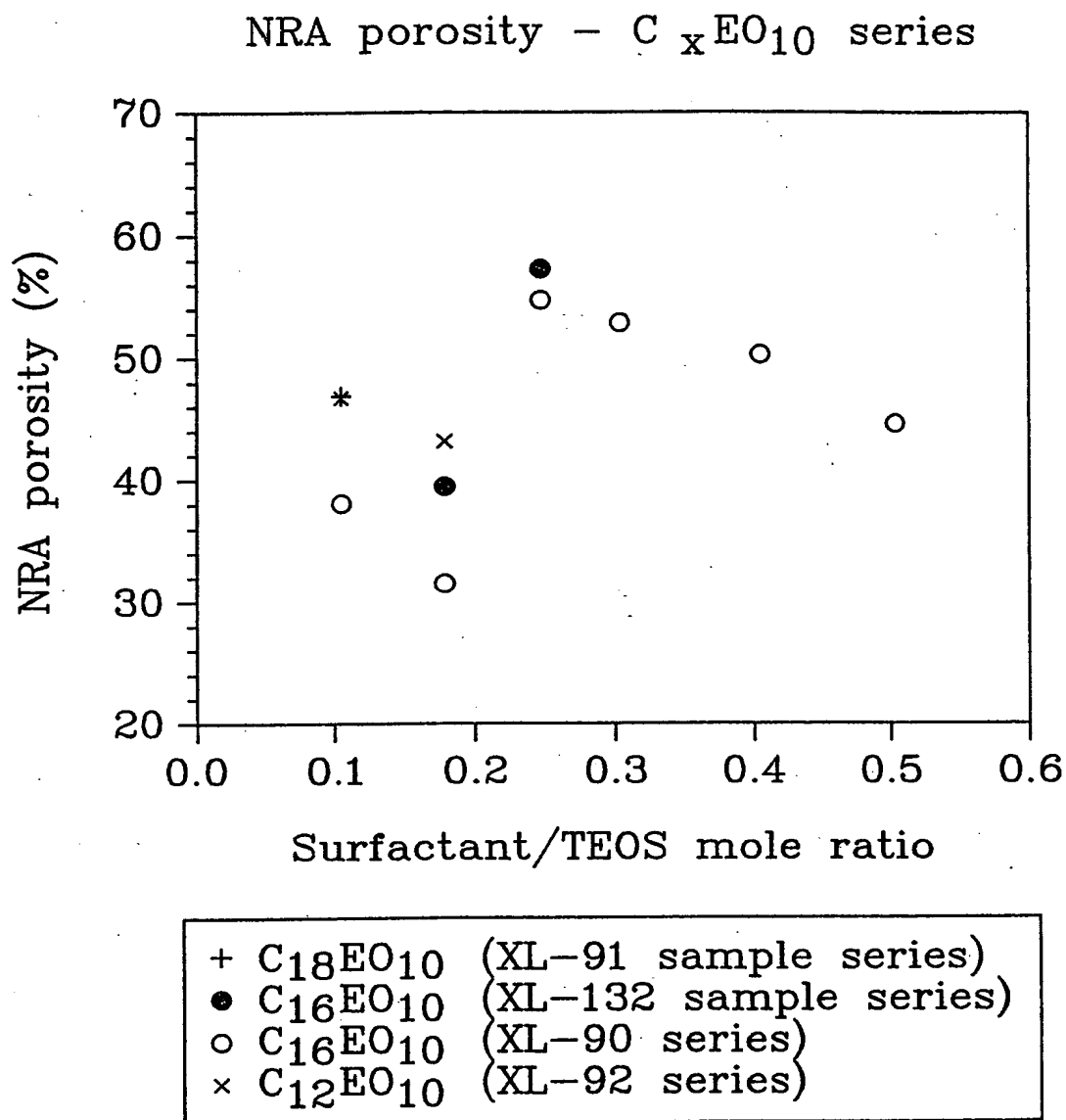


Fig. 1

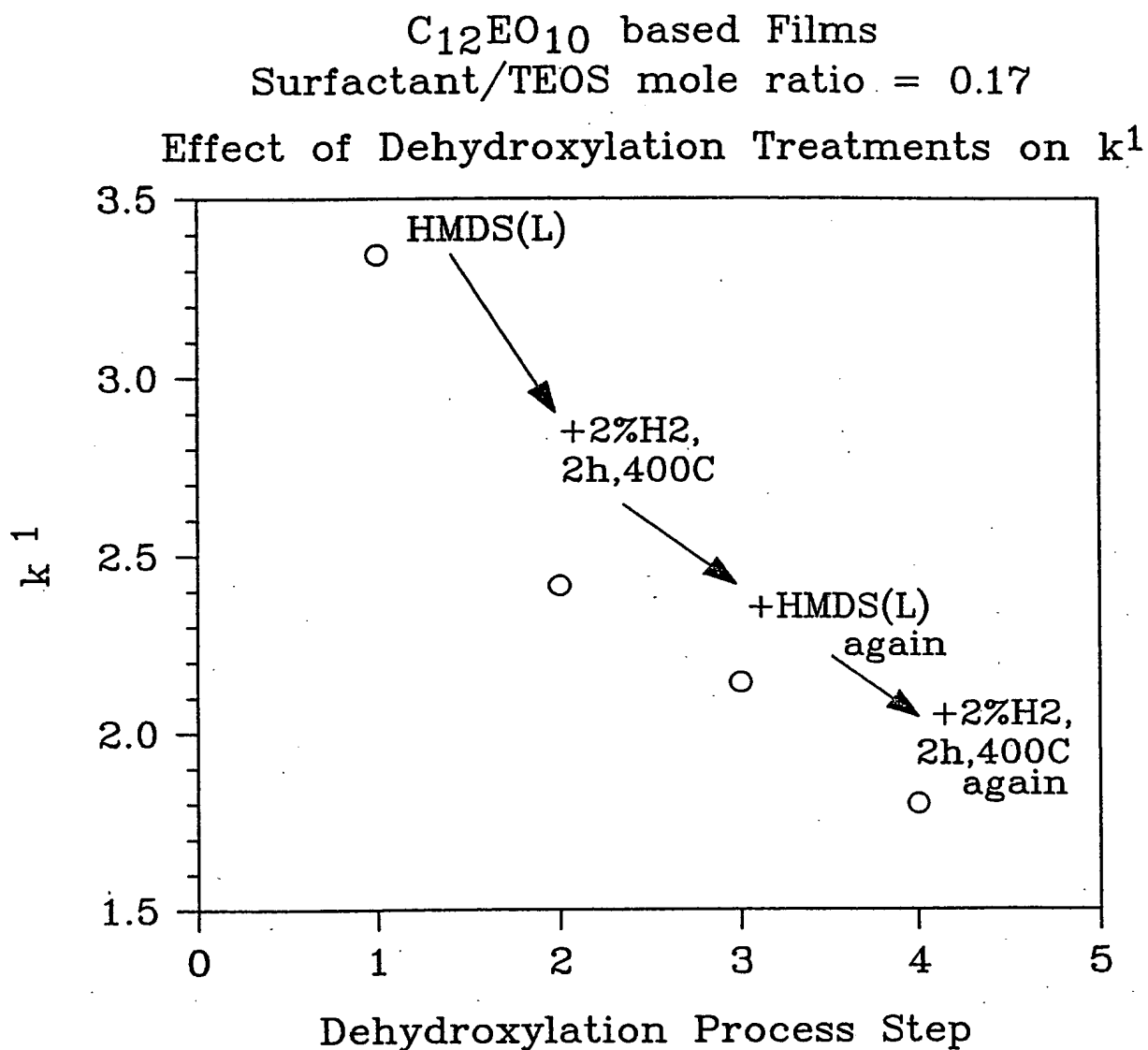


Fig. 2

$C_{16}EO_{10}$ based Films
Surfactant/TEOS mole ratio = 0.3

Effect of Dehydroxylation Treatments on k^1

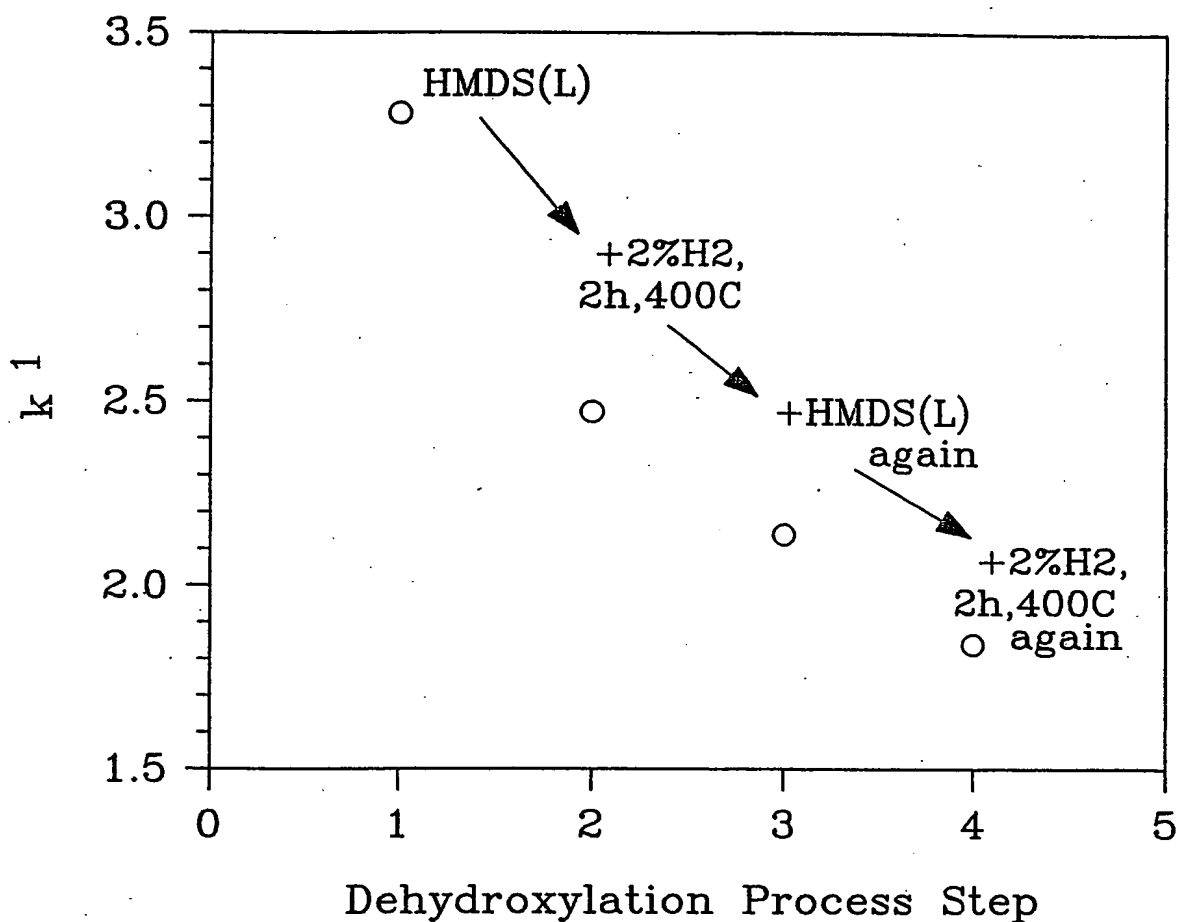


Fig. 3

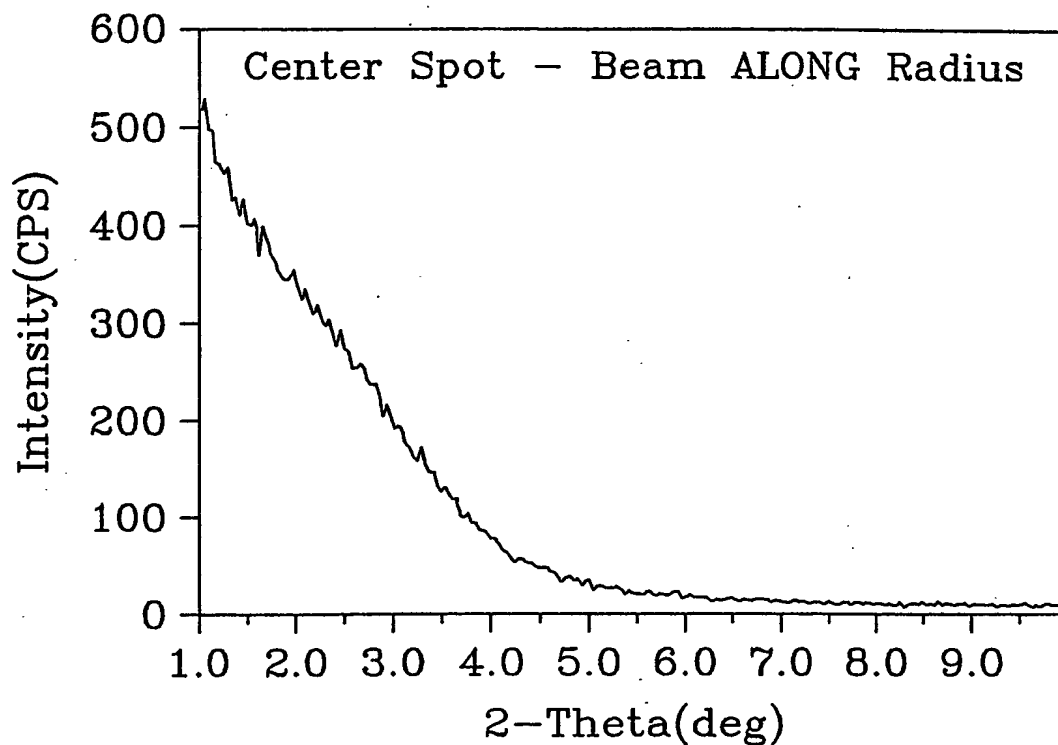


Fig. 4a

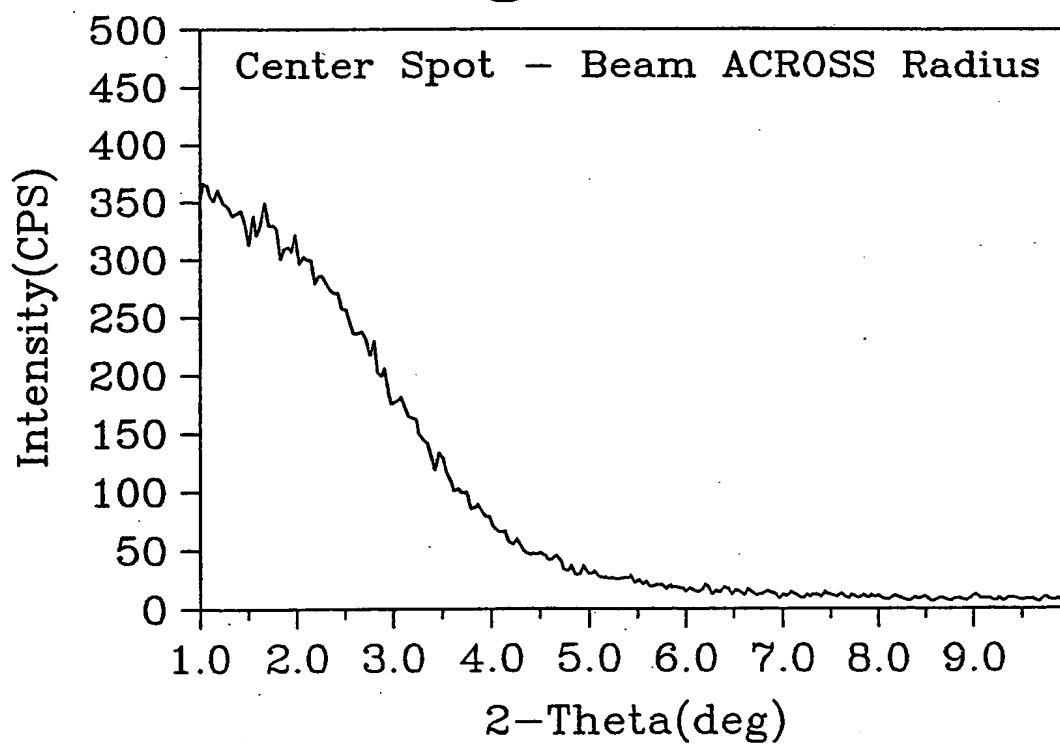


Fig. 4b

In re patent application of Liu, et al
Invention: MESOPOROUS SILICA FILM FROM
SOLUTION CONTAINING A SURFACTANT AND
METHODS OF MAKING SAME
Filing Date: April 18, 2000
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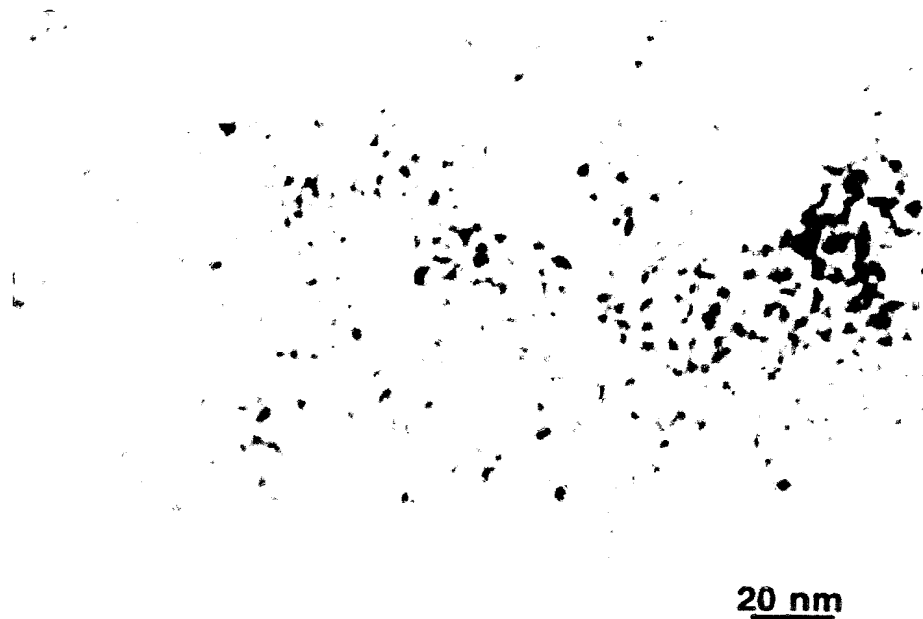


Fig. 5

10/11/00 10:00 AM

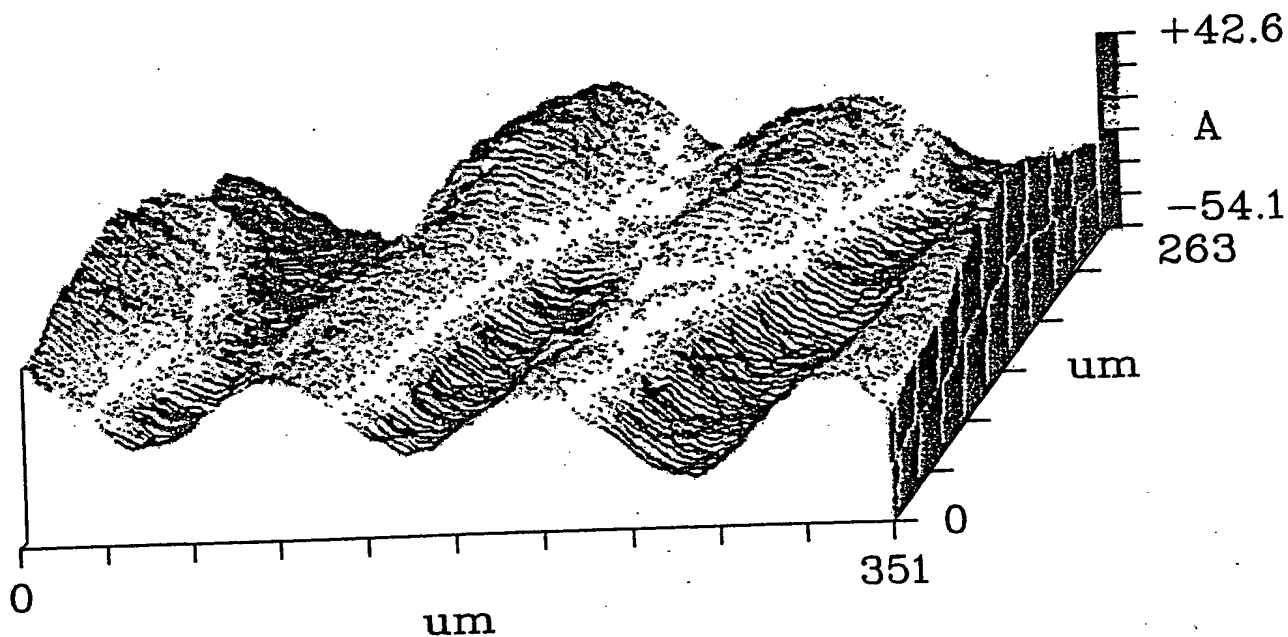


Fig. 6a

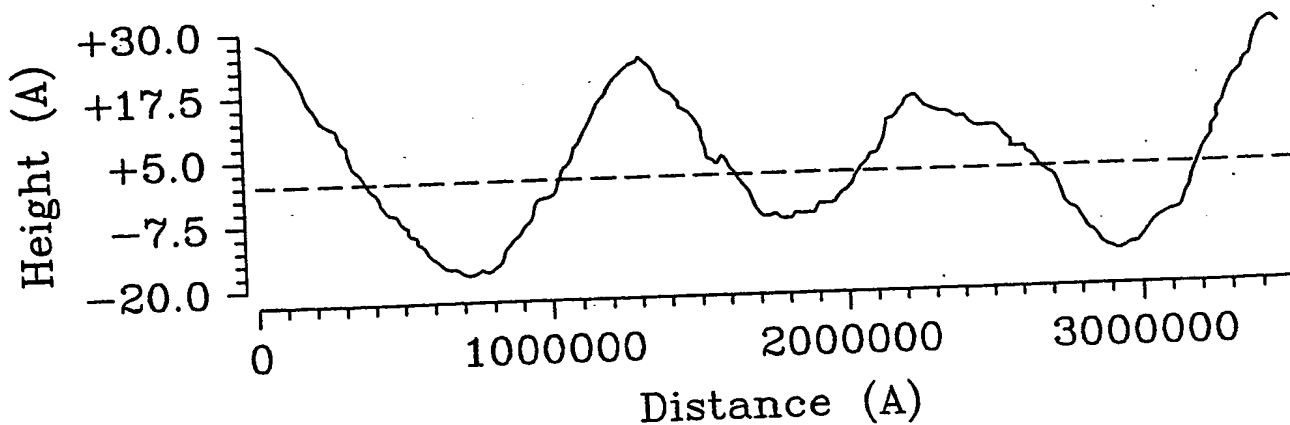


Fig. 6b

Modulus between 14 and 17 GPa
obtained for 50–300 microNewton loads

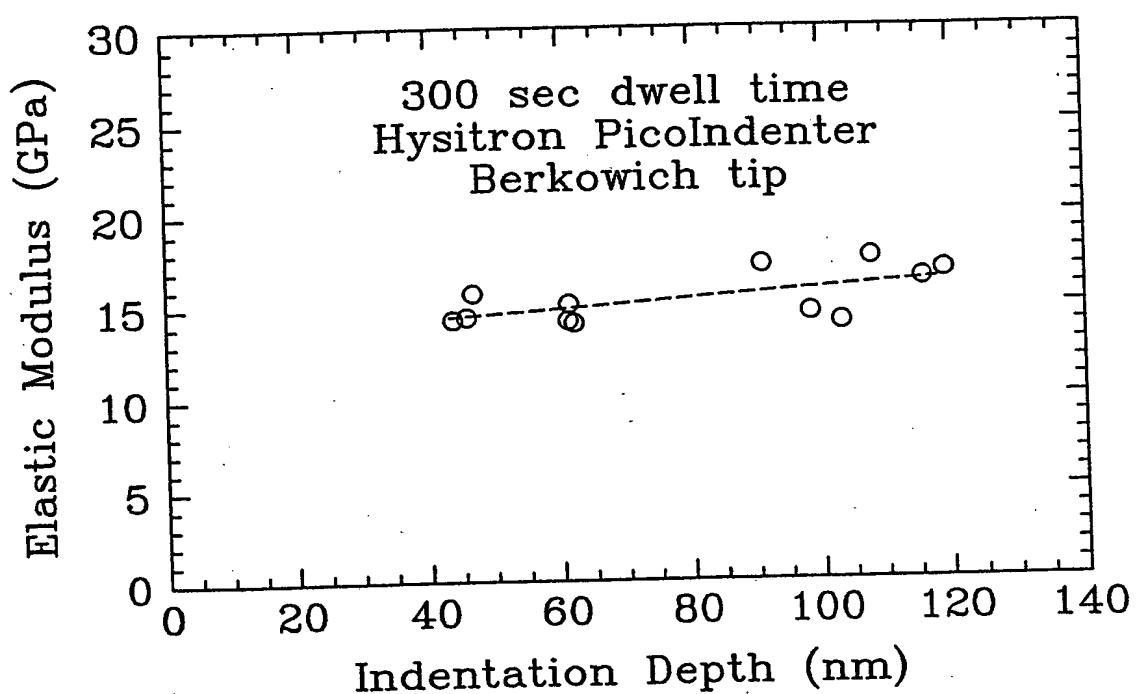


Fig. 7

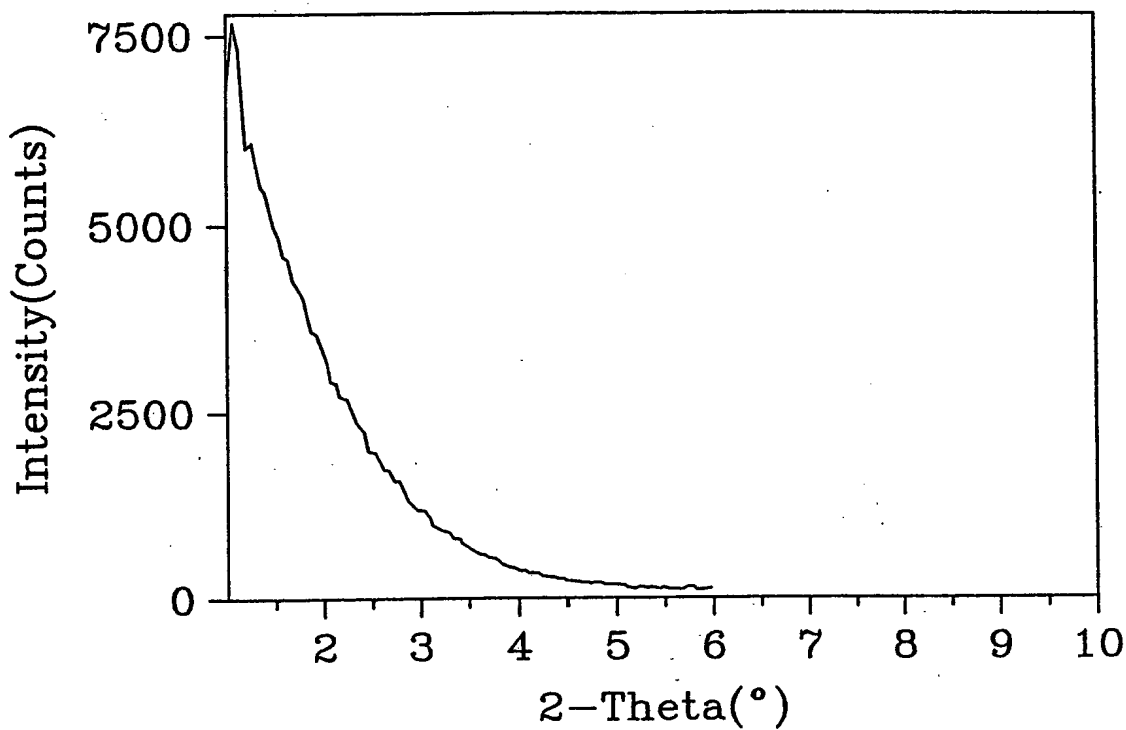


Fig. 8a

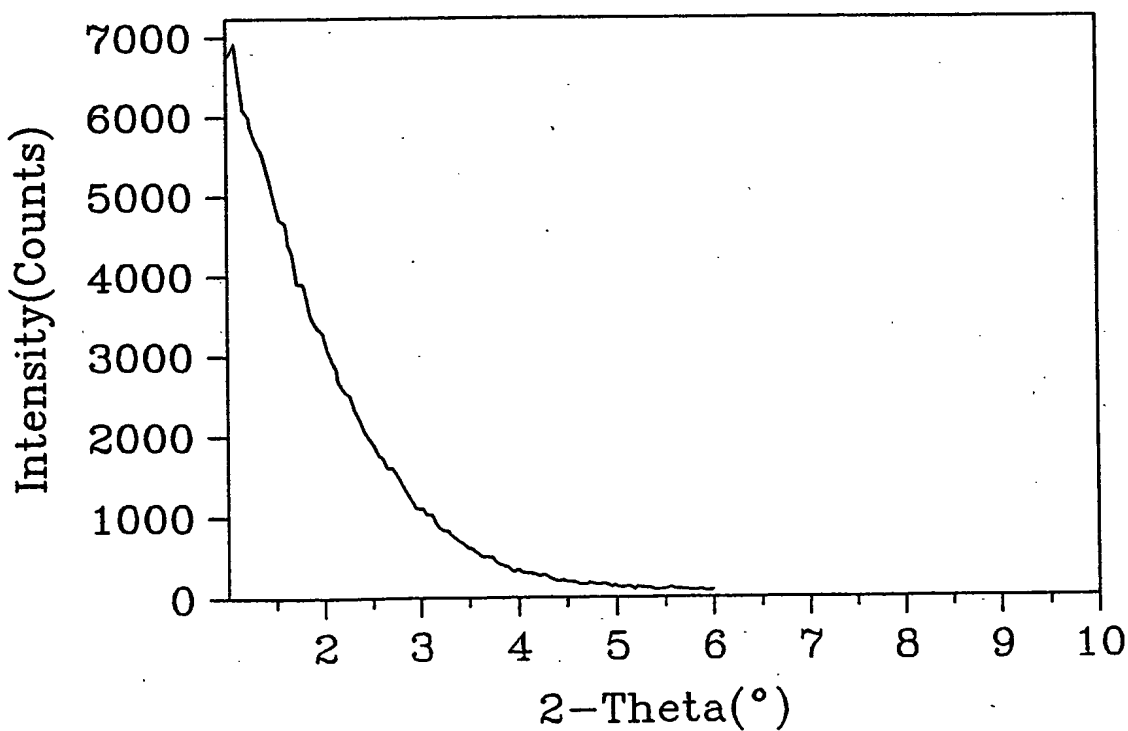


Fig. 8b

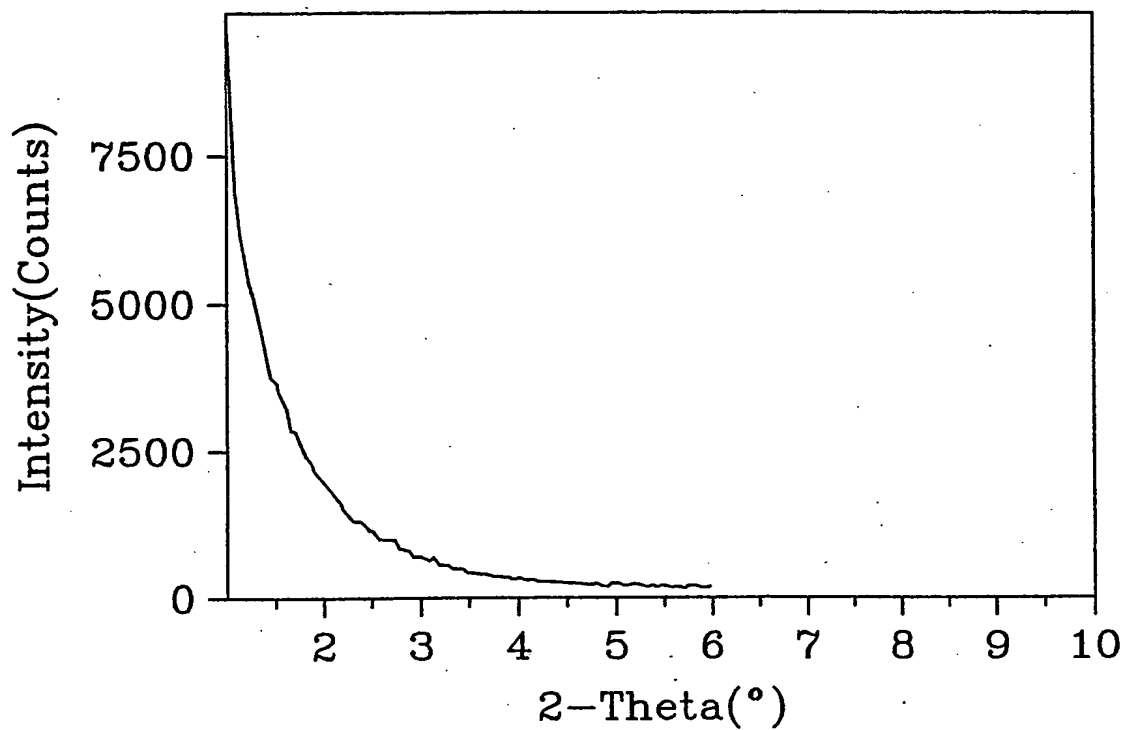


Fig. 9a

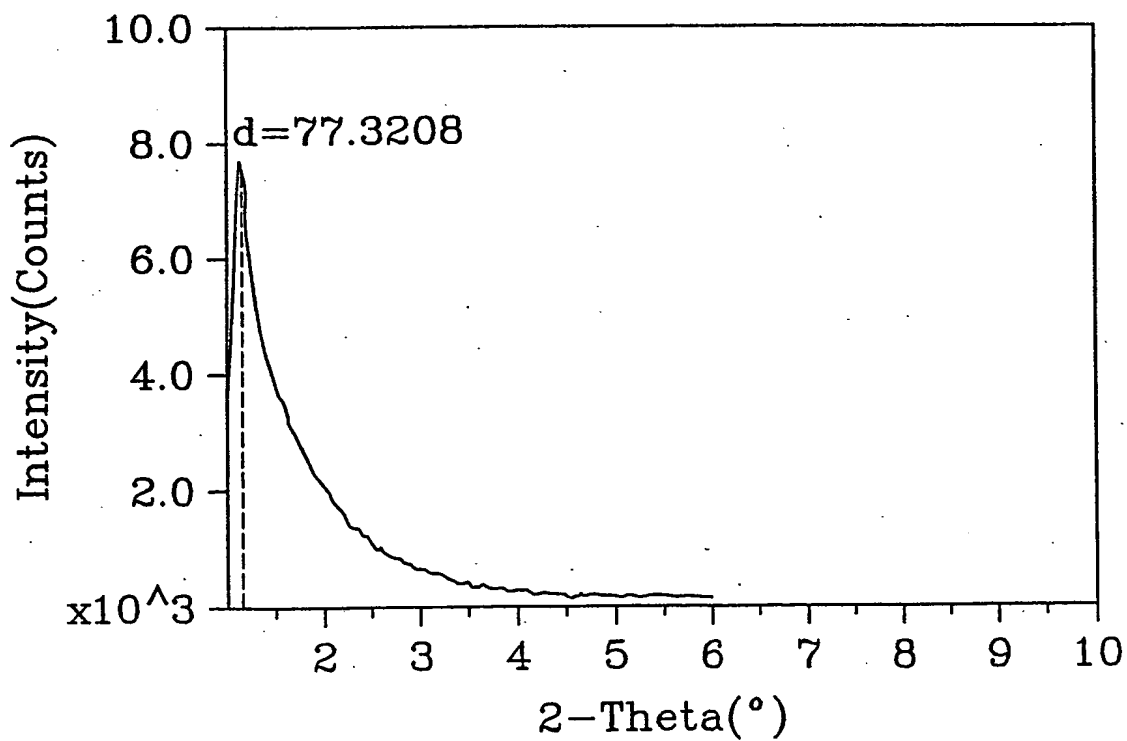


Fig. 9b

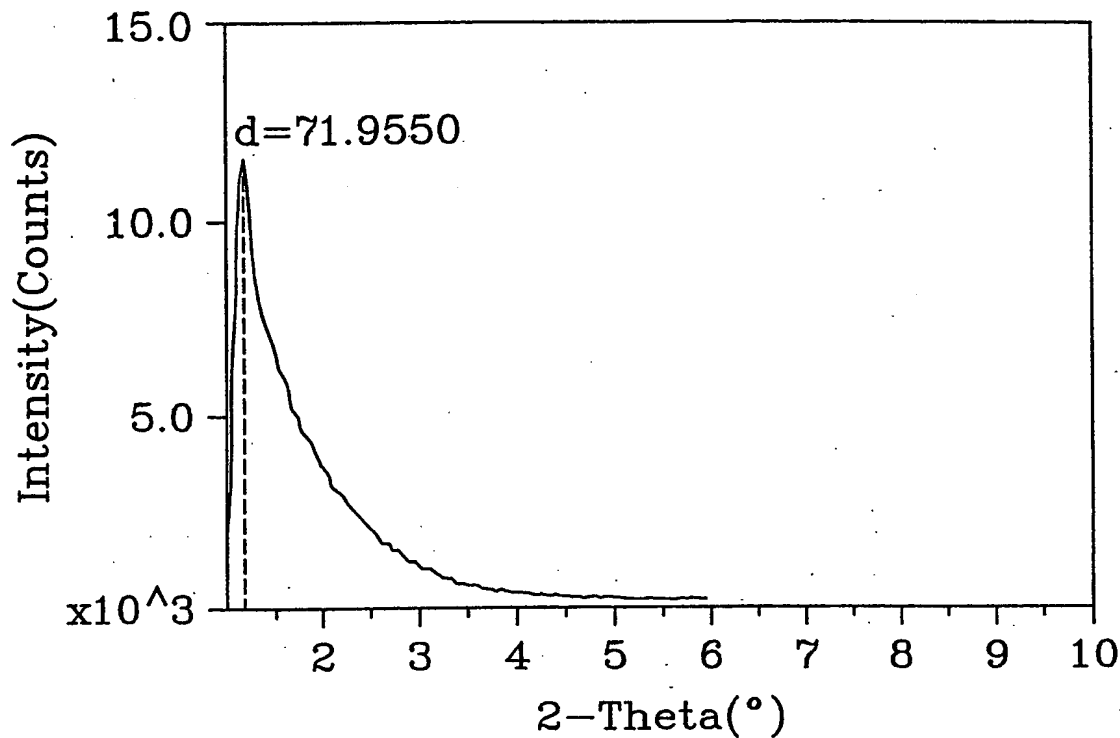


Fig. 10a

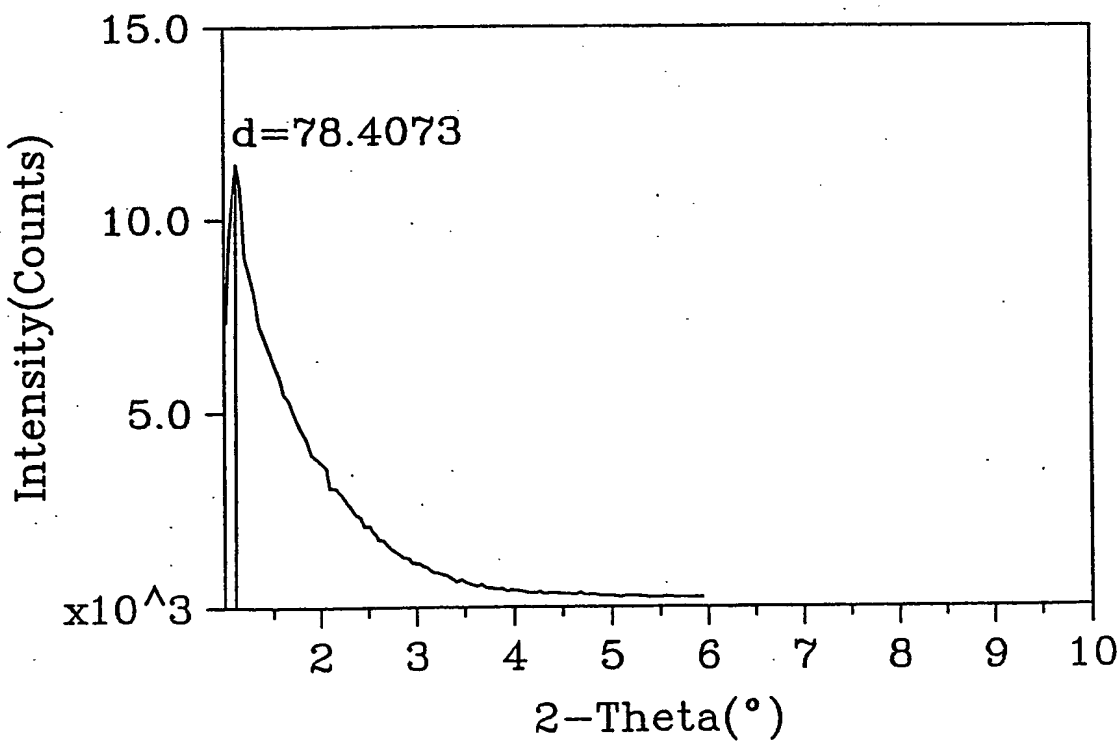


Fig. 10b

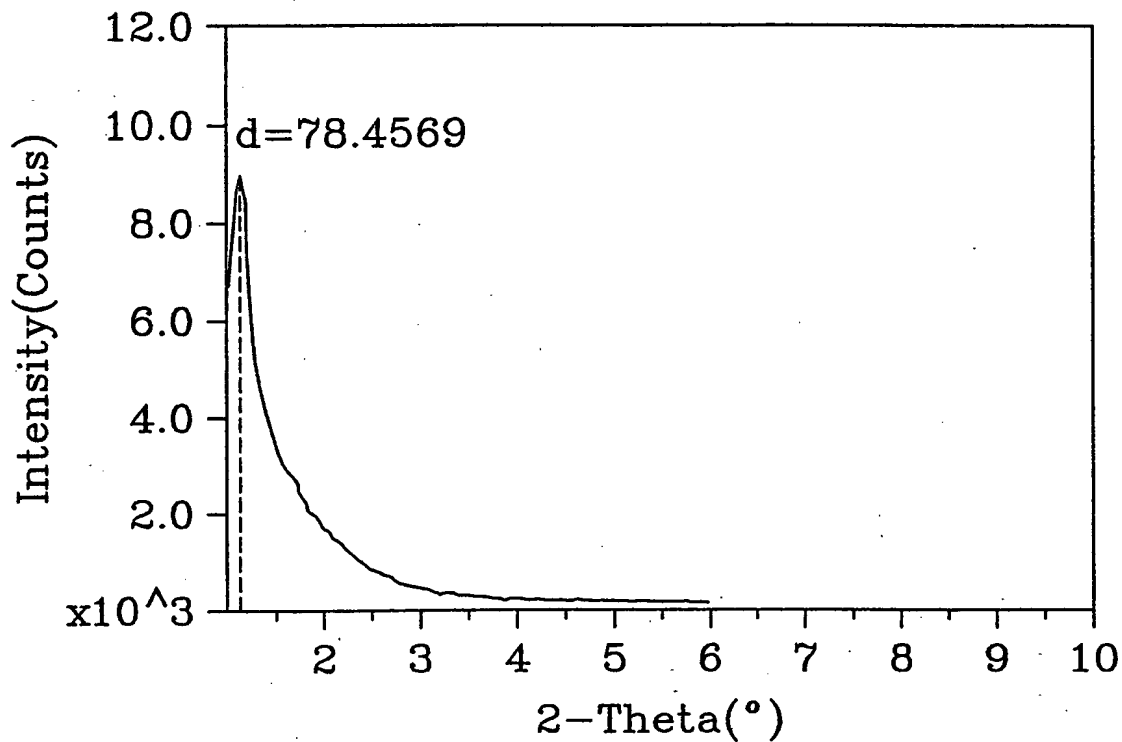


Fig. 11a

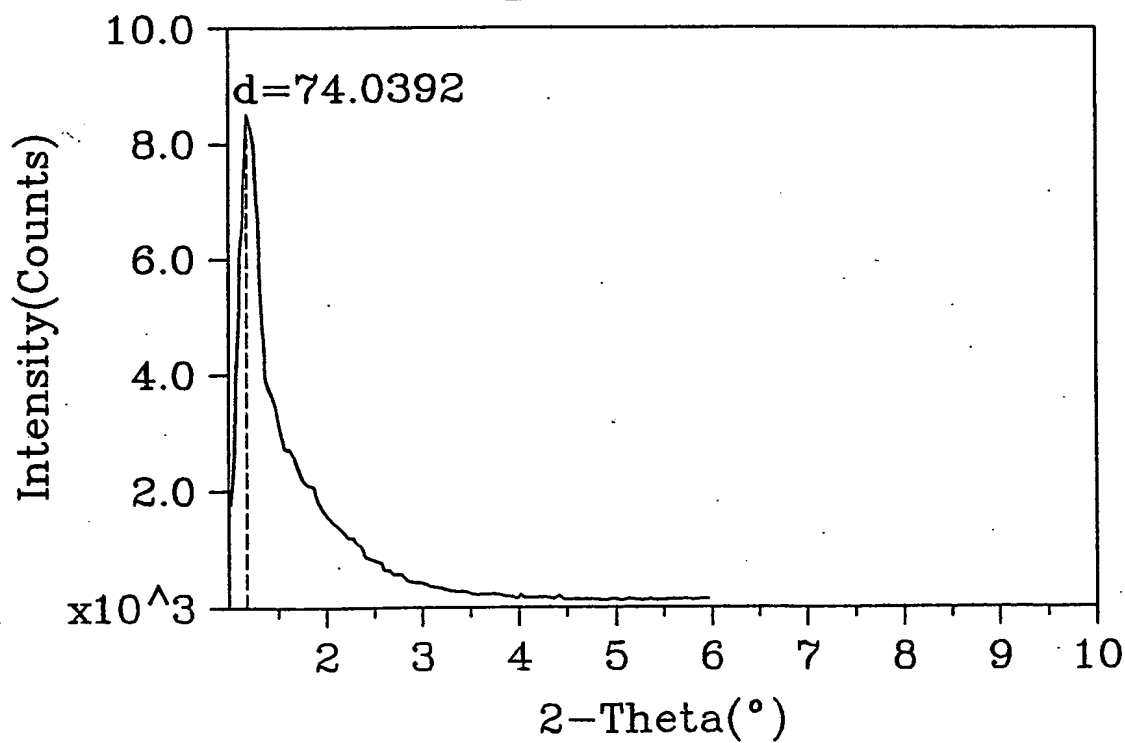


Fig. 11b

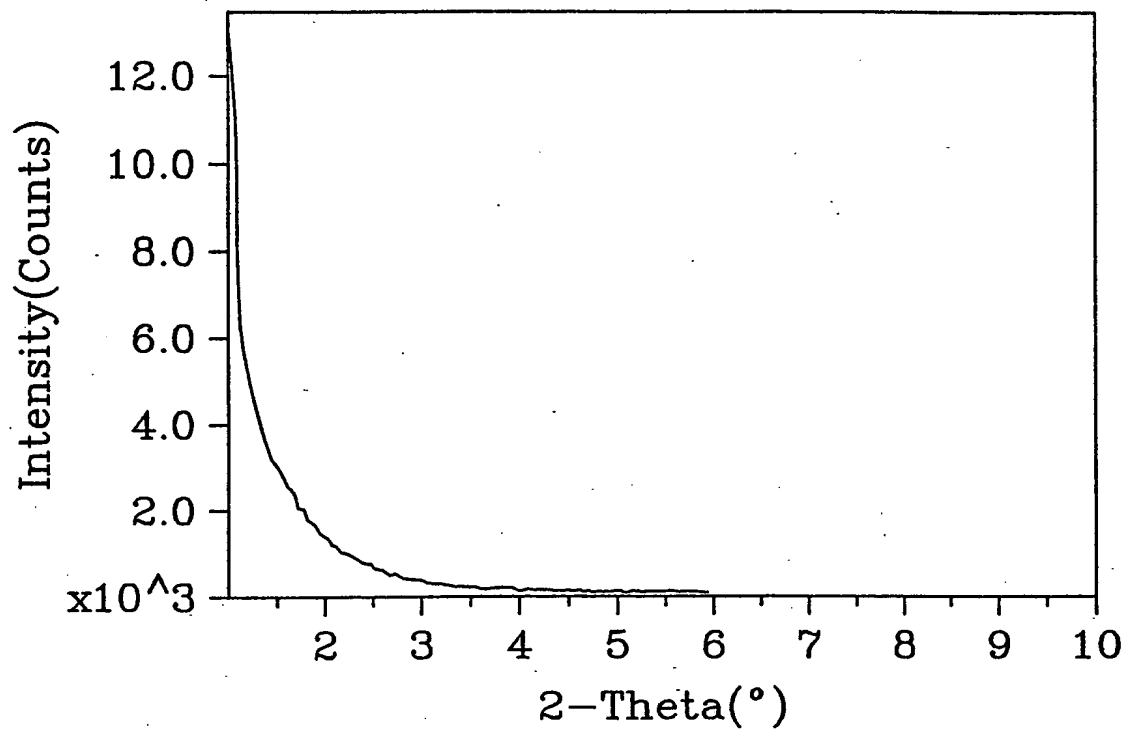


Fig. 12a

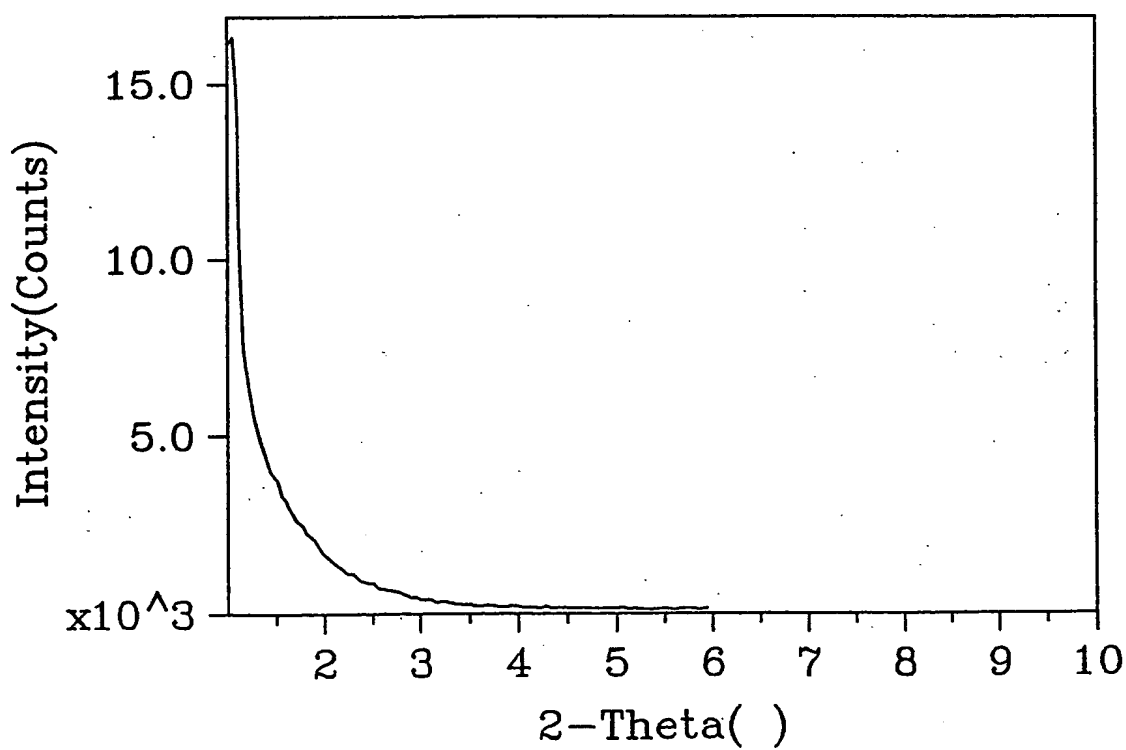


Fig. 12b

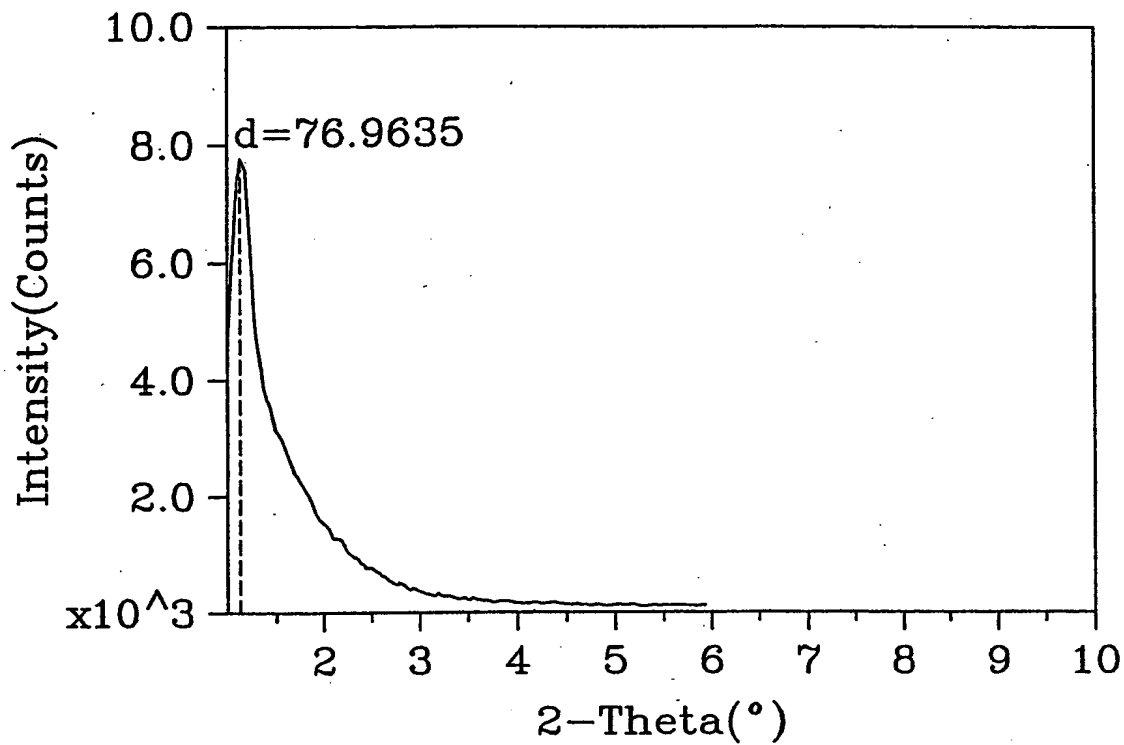


Fig. 12c

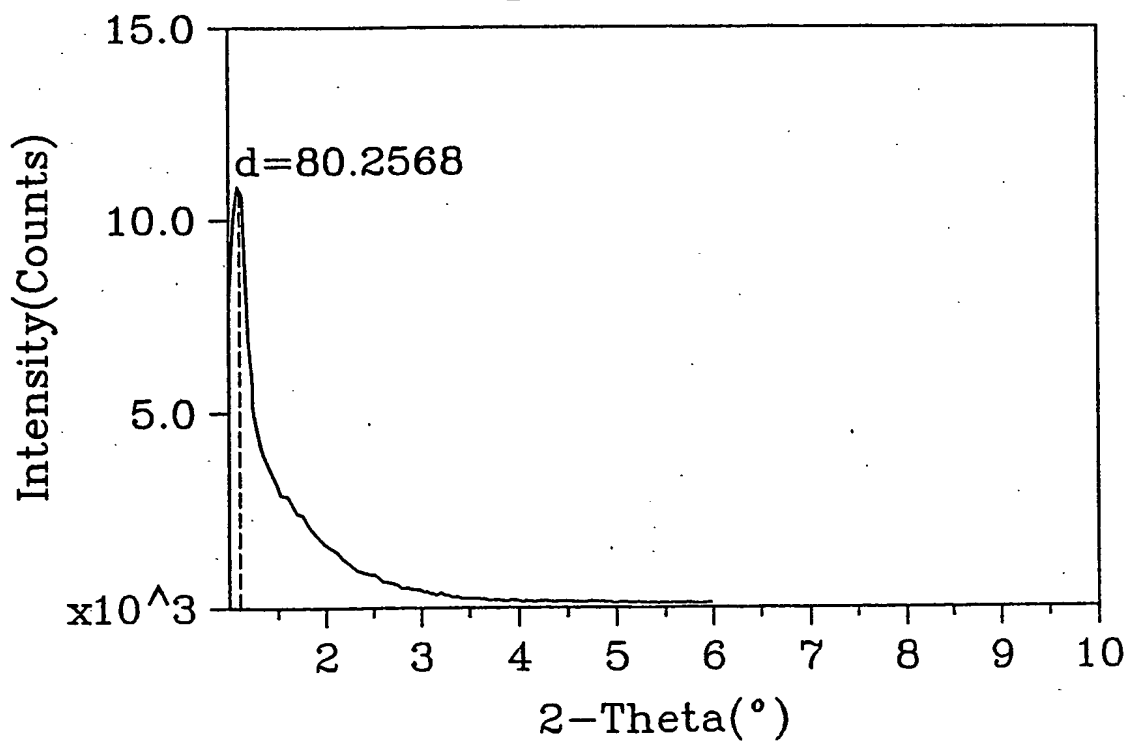
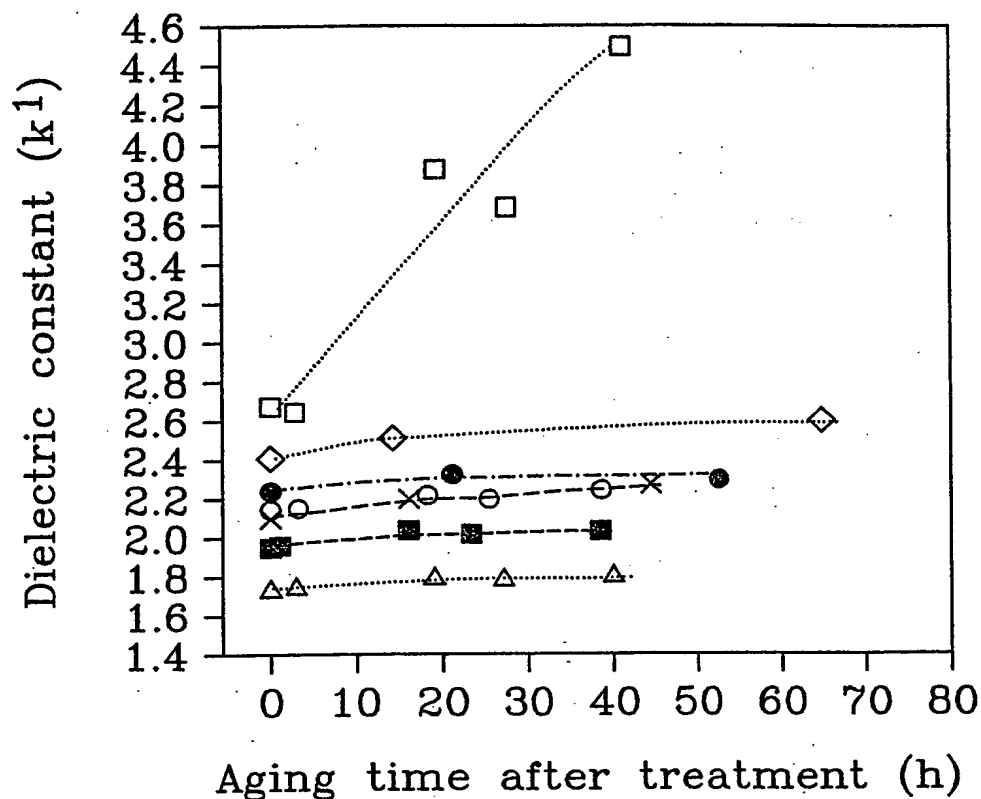


Fig. 12d



- 2%H₂,2h,400°C (103-2-1-B1)
- ◇ HMDS (L)>>2%H₂,2h,400°C (XL-92-2)
- HMDS (L)>>2%H₂,2h,400°C>>HMDS(L) (103-2-I-A1)
- △ HMDS (L)>>2%H₂,2h,400°C>>HMDS(L)>>2%H₂,2h,400°C (103-2-I-A2)
- HMDS (L)>>Ar,2h,400°C (103-2-1-B2)
 HMDS (L)>>Ar,2h,400°C>>HMDS(L) >>Ar,2h,400°C (112-1-III-D2)
- × HMDS spin coat>>2%H₂,2h,400°C>>
 HMDS spin coat>>2%H₂,2h,400 C (103-2-1-C1)

Fig. 13